

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In repatent application of

Docket No.: FIS920030183US1

Dureseti Chidambarrao, et al.

Serial No.: 10/605,108

Group Art Unit: 2107

Filed: September 9, 2003

Examiner: Pham, Long

For:

METHOD FOR REDUCED N+ DIFFUSION IN STRAINED SI ON SIGE

SUBSTRATE

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

SUBMISSION OF FORMAL DRAWINGS

Sir:

Submitted herewith, are three (3) sheets of formal drawings comprising figures 1-7 for the above-identified patent application. Please substitute the formal drawings for the drawings which were filed with the application.

Respectfully submitted,

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